REMARKS

The rejections of Claims 1-4 and 7-10 as being unpatentable over Ishii in

view of Masuda et al. and Nakajima et al., of Claims 5 and 6 as being

unpatentable over the foregoing three documents and further in view of Ye et al.,

of Claim 11 as being unpatentable over said three documents and further in view

of Steger et al., and of Claim 12 as being unpatentable over said three documents

and further in view of Otsuki, all under 35 U.S.C. § 103(a), are traversed.

Reconsideration of each of these rejections is respectfully requested in light of

the above amendments and following comments.

The claimed shield electrode designated by numeral 15 in Fig. 1 surrounds

the vacuum reactor. The power source 16 provides a high frequency power that

is lower than the power provided by the power source 8 as the power of the latter

may be equal to that of the power source 16 (page 9, lines 5-9 and lines 22-24).

Thereby, the voltage potential on the outer circumferential wall of the vacuum

reactor can be set to a value below the plasma voltage potential, and deposition

of the reaction products on the inner wall is prevented (page 11, lines 5-15).

The cited documents relied upon in the Office Action do not, either singly

or in combination, teach or even suggest the now claimed shield structure or the

result produced thereby. For example, the shield electrode of Nakajima et al. is

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not arranged so as to control the voltage potential of an outer circumferential

wall of a vacuum reactor.

Accordingly, early and favorable action is currently solicited. If there are

any questions regarding this amendment or the application in general, a

telephone call to the undersigned would be appreciated since this should

expedite the prosecution of the application for all concerned.

If necessary to effect a timely response, this paper should be considered as

a petition for an Extension of Time sufficient to effect a timely response, and

please charge any deficiency in fees or credit any overpayments to Deposit

Account No. 05-1323 (Docket #056204.53113US).

Respectfully submitted,

Dated: March 30, 2006

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